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Optimal rubbing angle for reflective in-plane-switching liquid crystal displays

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Rubbing angle effects on the response time and optical threshold voltage of the reflective in-plane-switching homogeneous liquid crystal displays were analyzed. As the rubbing angle increases, the rise time decreases except that its operating voltage also increases. The optimal rubbing angle is around 30°–40°. © 2002 American Institute of Physics.

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Reflective liquid crystal displays (LCDs)¹ offer several advantages over the transmissive ones in low power consumption, sunlight readability, and film-like image quality. The in-plane switching (IPS) mode has been used for large-screen transmissive LCDs because of its wide viewing angle.^{2–4} Recently, the IPS mode has been extended to reflective liquid crystal displays.^{5–8} As expected, wide viewing angle and high contrast ratio are obtained for the reflective IPS mode. However, the response time of the IPS mode is relatively slow as compared to other modes.⁹ In the IPS mode, the LC response time depends on the cell gap, rotational viscosity, twist elastic constant, applied electric field, and the rubbing angle (Φ).¹⁰ Among these parameters, the rubbing angle effect has not been analyzed in detail due to the difficulty in defining the optical transition threshold.

In this letter, we derived the IPS LC director's dynamic response by solving the Erickson–Leslie equation. This derivation is also valid to the transmissive IPS mode, although our emphasis is for reflective displays. The rubbing angle effects are described quantitatively.

Figure 1 shows the electrode configuration of the IPS mode under study. The comb-shaped electrodes are in the top substrate where $z=0$ in order to separate from the bottom reflector. The electrode gap is ℓ ($\sim 10\ \mu\text{m}$) and width ω ($\sim 5\ \mu\text{m}$). When backflow and inertial effects are ignored, the dynamics of liquid crystal director rotation is described by the following Erickson–Leslie equation:^{4,9}

$$\gamma_1 \frac{\partial \phi}{\partial t} = K_2 \frac{\partial^2 \phi}{\partial z^2} + \epsilon_0 |\Delta \epsilon| E^2 \sin \phi \cos \phi. \quad (1)$$

In Eq. (1), γ_1 is the rotational viscosity, K_2 is the twist elastic constant, $\Delta \epsilon$ is the dielectric anisotropy, E is the electric field strength, and ϕ is the LC rotation angle. The homogeneous LC layers having cell gap d are along the z axis.

In our analysis, we assume the surface anchoring strength is strong so that the bottom and top boundary layers are fixed at $\phi(0) = \phi(d) = \Phi$, where Φ is the LC alignment (or rubbing) angle with respect to the electrodes, as shown in Fig. 1. The middle layer has the maximum twist deformation

angle $\phi(d/2) = \phi_m$. Using these initial conditions, in a steady state the electric field-induced twist angle ϕ_0 along the z axis could be approximated as

$$\phi_0(z) = \Phi + (\phi_m - \Phi) \sin\left(\frac{\pi z}{d}\right). \quad (2)$$

First, let us consider the relaxation process. We assume the electric field is removed instantaneously at time $t=0$. The relaxation time τ for returning from the activated state to the initial state has the following exponential form:

$$\phi(z, t) = \Phi + (\phi_m - \Phi) \sin\left(\frac{\pi z}{d}\right) \exp(-t/\tau). \quad (3)$$

Substituting Eq. (3) into Eq. (1), we derive the free relaxation time

$$\begin{aligned} & -\frac{\gamma_1}{\tau} (\phi_m - \Phi) \sin(\pi z/d) \exp(-t/\tau) \\ & = -\frac{K_2 \pi^2}{d^2} (\phi_m - \Phi) \sin(\pi z/d) \exp(-t/\tau). \end{aligned} \quad (4)$$

From Eq. (4), the relaxation time can be solved easily

$$\tau_{\text{off}} = \frac{\gamma_1 d^2}{\pi^2 K_2}. \quad (5)$$

From Eq. (5), the relaxation time is governed by the cell gap (d) and the LC viscoelastic coefficient (γ_1/K_2), and is independent of the rubbing angle.

FIG. 1. Device structure of the reflective IPS LCD. The rubbing direction is at an angle Φ with respect to the IPS electrodes. ℓ = electrode gap and ω = electrode width.

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FIG. 2. Voltage-dependent reflectance of a reflective IPS homogeneous LC cell at 10° and 30° rubbing angles. $d=3\text{ }\mu\text{m}$, $\Delta n=0.06$, $\ell=10\text{ }\mu\text{m}$, and $\lambda=550\text{ nm}$.

Next, we analyzed the switching-on process. The LC directors are described as¹¹

$$\phi(z, t) = \Phi + (\phi_m - \Phi) \sin\left(\frac{\pi z}{d}\right) \exp[(t - \tau)/\tau]. \quad (6)$$

Substituting Eq. (6) in to Eq. (1), we find

$$\begin{aligned} & \frac{\gamma_1}{\tau} (\phi_m - \Phi) \sin\left(\frac{\pi z}{d}\right) \exp[(t - \tau)/\tau] \\ &= -K_2 \frac{\pi^2}{d^2} (\phi_m - \Phi) \sin\left(\frac{\pi z}{d}\right) \exp[(t - \tau)/\tau] \\ &+ \varepsilon_0 |\Delta \varepsilon| E^2 \sin(\Phi + x) \cos(\Phi + x). \end{aligned} \quad (7)$$

In Eq. (7), the parameter x is defined as

$$x = (\phi_m - \Phi) \sin\left(\frac{\pi z}{d}\right) \exp[(t - \tau)/\tau]. \quad (8)$$

Let $\bar{x} = \int_0^{d/2} x dz$. At $t = \tau$, $\bar{x} = 2/\pi (\phi_m - \Phi)$ where $(\phi_m - \Phi)$ represents the twisted angle of the middle LC layer under the exerted electric field. Using Eq. (8), Eq. (7) can be rewritten as follows:

$$\tau_{\text{on}} = \frac{\gamma_1}{\varepsilon_0 |\Delta \varepsilon| E^2 \left[\cos(2\Phi) \frac{\sin(2\bar{x})}{2\bar{x}} + \sin(2\Phi) \frac{\cos(2\bar{x})}{2\bar{x}} \right] - \frac{\pi^2}{d^2} K_2}. \quad (12)$$

For a given electric field, $\bar{x}$ can be obtained from ϕ_m which, in turn, is calculated from the following elliptical equation:¹²

$$\frac{Ed}{2} \sqrt{\frac{\varepsilon_0 |\Delta \varepsilon|}{K_2}} \sin \phi_m = \int_{\Phi}^{\phi_m} \frac{1}{\sqrt{1 - (\sin \phi / \sin \phi_m)^2}} d\phi. \quad (13)$$

Strictly speaking, when the rubbing angle $\Phi \neq 0$ there exists no Freedericksz transition threshold. However, in a normally black IPS mode, the reflectance is proportional to the phase retardation $\delta = 2(2\pi d \Delta n / \lambda)$ of the LC cell as $R \sim \sin^2(\delta/2)$. In the small voltage regime, the phase retarda-

FIG. 3. Rubbing angle dependent rise time of a reflective IPS LCD. LC cell has homogeneous alignment and cell gap $d=3\text{ }\mu\text{m}$, $\gamma_1=0.1\text{ Pa s}$ and $K_2=7\text{ pN}$.

$$\begin{aligned} \frac{\gamma_1}{\tau} \bar{x} = & -K_2 \frac{\pi^2}{d^2} \bar{x} + \frac{1}{2} \varepsilon_0 |\Delta \varepsilon| E^2 [\sin(2\Phi) \cos(2\bar{x}) \\ & + \cos(2\Phi) \sin(2\bar{x})]. \end{aligned} \quad (9)$$

When the rubbing angle $\Phi = 0$, the LC directors are perpendicular to the electric field and the Freedericksz transition exists. Under this circumstance, the turn-on time is

$$\tau_{\text{on}} = \frac{\gamma_1}{\varepsilon_0 |\Delta \varepsilon| E^2 \frac{\sin(2\bar{x})}{2\bar{x}} - \frac{\pi^2}{d^2} K_2}. \quad (10)$$

In principle, Eq. (10) is not limited to the small signal regime. In the usual small angle approximation (i.e., the electric field is only slightly above threshold), $\bar{x} \ll 1$ and the rise time is reduced to the following commonly known equation:

$$\tau_{\text{on}} = \frac{\gamma_1}{\varepsilon_0 |\Delta \varepsilon| E^2 - \frac{\pi^2}{d^2} K_2}. \quad (11)$$

When the rubbing angle $\Phi \neq 0$, we can also obtain τ_{on} as

tion is small and R exhibits a threshold-like transition. In our simulations, the rise time is defined based on the reflectance change from R_0 to R_{90} .

This optical threshold voltage (V_{op}) can be derived by assuming that the rise time is approaching infinity at $V = V_{\text{op}}$. Thus, the denominator in Eq. (12) should vanish

$$\begin{aligned} & \varepsilon_0 |\Delta \varepsilon| E^2 \left[\cos(2\Phi) \frac{\sin(2\bar{x})}{2\bar{x}} + \sin(2\Phi) \frac{\cos(2\bar{x})}{2\bar{x}} \right] \\ & - \frac{\pi^2}{d^2} K_2 \rightarrow 0. \end{aligned} \quad (14)$$

From Eq. (14), the optical threshold voltage is expressed as

$$V_{op} = E \cdot \ell = \frac{\pi \ell}{d} \sqrt{\frac{K_2}{\epsilon_0 |\Delta \epsilon| \left[\cos(2\Phi) \frac{\sin(2\bar{x})}{2\bar{x}} + \sin(2\Phi) \frac{\cos(2\bar{x})}{2\bar{x}} \right]}}. \quad (15)$$

From Eq. (15), when $\Phi = 0$ and $\bar{x} \rightarrow 0$, the optical threshold is reduced to the Freedericksz threshold.¹³ As the rubbing angle is increased, the optical threshold voltage is gradually decreased. At $\Phi = 45^\circ$, the optical threshold voltage has a minimum.

In our calculations for a reflective IPS mode, we have placed the interdigitated indium tin oxide electrodes in the top substrate and an aluminum reflector in the bottom substrate. A quarter-wave film is needed between the bottom LC substrate and the reflector in order to obtain the normally black mode. The TFT aperture ratio was not taken into account. The following LC cell parameters are used for calculations: $d = 3 \mu\text{m}$, $\gamma_1 = 0.1 \text{ Pa s}$, $K_2 = 7 \text{ pN}$, $\Delta \epsilon = 7.8$, $\Delta n = 0.06$, $\ell = 10 \mu\text{m}$, and $\omega = 5 \mu\text{m}$. Figure 2 plots the voltage-dependent reflectance of the homogeneous LC cell at $\lambda = 550 \text{ nm}$ for two rubbing angles $\Phi = 10^\circ$ and 30° . At $\Phi = 10^\circ$, the optical threshold ($R = 10\%$) is $\sim 2.1 V_{\text{rms}}$ while at $\Phi = 30^\circ$ the threshold is reduced to $\sim 1.6 V_{\text{rms}}$. The on-state voltage for $\Phi = 30^\circ$ is slightly higher than that for $\Phi = 10^\circ$.

The major advantage for the increased rubbing angle is on the improved rise time. Figure 3 shows the rubbing angle dependent rise time at three gray levels: $R = 10\%$, 50% , and 100% ; here R stands for the normalized reflectance. As the rubbing angle increases, the rise time decreases. For example, the conventional IPS cell uses $\Phi \sim 10^\circ$. Its rise time for the $R = 100\%$ curve is 35 ms . By merely changing the rubbing angle to $\Phi = 30^\circ$, the rise time is reduced to 15 ms .

As discussed in Eq. (5), the rubbing angle makes no effect to the decay time.

Although rubbing angle makes a significant effect on the rise time, we have to evaluate its impact on the operating voltage. Figure 4 plots the simulated results on the rubbing angle dependent operating voltage at three gray levels, $R = 10\%$, 50% , and 100% . The optical threshold voltage which corresponds to R_{10} decreases as the rubbing angle Φ increases, reaches a minimum at $\Phi = 45^\circ$ and then slowly bounces back. The analytical results using Eq. (15) overlap well with the square data points that are calculated without any approximation. From Fig. 4, the on-state voltage (corresponding to $R = 100\%$) increases noticeably as $\Phi > 35^\circ$. If the maximum voltage of the amorphous silicon thin film transistor is $5 V_{\text{rms}}$, then the optimal rubbing angle should be set in the 30° – 40° range for achieving faster rise time.

In conclusion, we have analyzed the rubbing angle effects on the rise time and operating voltages of a reflective in-plane-switching homogeneous cell. In general, the rise time decreases as the rubbing angle increases. The tradeoff is its increased on-state voltage. The optimal rubbing angle occurs at around 30° – 40° . The analyses developed here can also apply to the transmissive IPS LC cells.

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FIG. 4. Rubbing angle dependent optical threshold ($R = 10\%$), gray level ($R = 50\%$) and on-state ($R = 100\%$) voltage. The fitting lines in $R = 10\%$ curve are calculated using Eq. (15).

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